

Multifractal patterns formed by laser irradiation in GeAl thin multilayer films

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Structures induced in GeAl thin multilayer films by laser irradiation are studied. We compute their multifractal spectra from digitized transmission-electron micrographs. The results show that the patterns, which arise from a diffusion process followed by rapid solidification, are fractal, and that they cannot be described by a unique scaling exponent.

I. INTRODUCTION

Fractal^{1,2} growth processes have been the subject of extensive experimental, numerical and theoretical studies in the last decade.^{3,4} Processes that give rise to the formation of very complex structures include, for example, dendritic solidification in an undercooled medium, viscous fingering, or electrochemical deposition. Fractal dimensions¹⁻⁴ have been widely employed in an attempt to relate the geometry of these structures to corresponding growth mechanisms. However, it has been recently suggested that multifractal scaling⁵ can be necessary to account for these and many other patterns appearing in nature. Thus, the growth probability distribution of diffusion-limited aggregation⁶ (DLA) clusters exhibit multifractal properties,⁷ and examples of this multifractal character of the growth probabilities have already been found experimentally in ammonium chloride crystals (Ref. 8) and iron oxide (Ref. 9) and Co (Ref. 10) magnetic particle aggregates. The *geometry* (see Sec. III below; see also Ref. 4 for a precise definition) of DLA clusters has also been found to have multifractal character;¹¹ however, it has been claimed that the up-to-date studied physical examples of DLA are not multifractal¹² in this geometrical sense.

Germanium compounds have previously received much attention as prototypes of the complicated behaviors happening in nonequilibrium solidification and/or crystallization of this and other materials.^{4,13} Thus, tree-shaped fractal crystals have been grown by heat treatment of amorphous GeSe₂ thin films,¹⁴ and DLA-like clusters, whose shape and dimension depends on the Au grain size appear upon ion implantation and annealing of GeAu bilayers.^{15,16} Besides, crystallization of amorphous Al_xGe_{1-x} thin films annealed at around 500 K,^{17,18} or spontaneous crystallization in laser-induced amorphous areas on Al_{0.6}Ge_{0.4} thin films¹⁹ show the so-called dense-branching morphology,¹⁷ which is a nonfractal although very intricate kind of pattern.

In this work we aim to provide evidence for geomet-

rically multifractal patterns formed in GeAl thin multilayer films by laser irradiation. The process we report in this paper, which has been thoroughly described elsewhere,²⁰ takes place in a range of temperatures and solidification velocities different from those of the above mentioned researches. In Sec. II we describe both the experimental and numerical procedures, including a brief account of previous work²⁰ regarding our samples. Section III contains the main part of the paper, including a detailed description of our computations and a tentative discussion of possible physical reasons for the appearance of multifractal patterns. Section IV concludes the paper summarizing our results.

II. EXPERIMENTAL AND NUMERICAL PROCEDURE

We work with four-layered thin films, with alternate layers of Ge and Al, a 50 at.% Al composition, a total film thickness in the 60-nm range, and a Ge layer at the surface. They are irradiated in air by means of single nanosecond pulses from a Xe-CI excimer laser with energy densities in the range 20-70 mJ cm⁻². Using Rutherford-backscattering spectrometry and transmission-electron microscopy (TEM) it is found²⁰ that the as-grown films consist of amorphous Ge and crystalline Al layers, and that laser irradiation induces the mixing of the layers; moreover, the degree of such mixing increases as laser energy density increases. This process occurs by diffusion of the elements within the liquid state followed by a rapid solidification process, which involves cooling rates in the 10⁹ K s⁻¹ range.

Among all the microstructures arising from laser irradiation,²⁰ we are interested in the Al cellular crystals formed at medium (≈ 45 mJ cm⁻²) energy densities. Typical TEM micrographs of these samples are shown in Fig. 1: Al crystals are seen there as dark regions, the background being an amorphous GeAl mixture. The degree of darkness of each crystal depends essentially on the concentration of Ge that has diffused into them. We

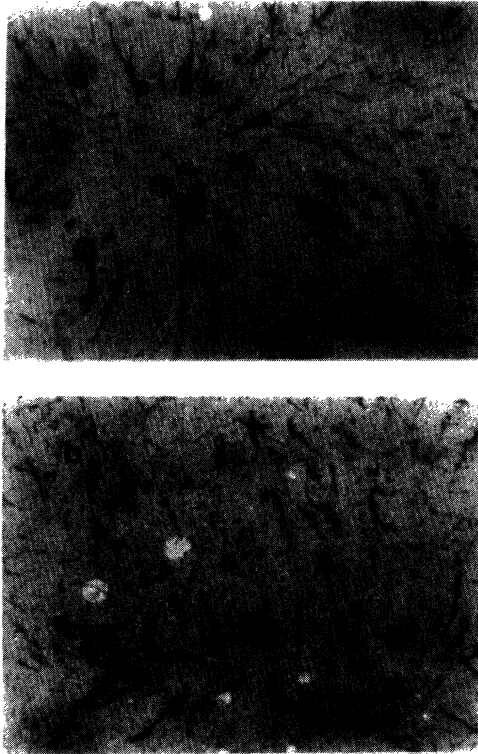


FIG. 1. TEM images of two areas, (a) and (b), of GeAl four-layered films after laser irradiation at 45 mJ cm^{-2} .

want to point out that these crystals form a quasi-two-dimensional pattern because their thickness is at most (definitely much less than) the film thickness (60 nm), while their typical length is around 500 nm; so, we can ignore the fact that TEM micrographs are actually two-dimensional projections of a three-dimensional structure.

Different micrographs including Al crystals in an amorphous matrix were digitized, measuring the optical density at 512×512 pixels, and their generalized dimensions and multifractal spectrum^{2,4,5} were computed. To be precise, the values provided by the digitizer are modified according the following rule: they are set to zero if they do not belong to a crystal (i.e., their optical density is less than or equal to that of the background) and they are taken to be the difference between their optical density and that of the background if they do belong to a crystal (i.e., their optical density is greater than the background value). This defines a positive measure on the set of crystals, which we finally normalize dividing each value among the sum of all of them. We have obtained the multifractal spectrum by two different methods. The first and simplest one was usual box-counting (see, e.g., Refs. 2, 4, 5, and 8) scaling (range, 1–64 pixels) of the sums of the q th power of the measure contained in each box; this yields directly the generalized dimensions D_q and subsequently the multifractal spectrum $f(\alpha)$ by a numerical Legendre transform. As is well known that this procedure suffers from enormous uncertainties in the negative q region, coming from finite size and resolution effects among other factors, we have checked our results with a second, more accurate technique proposed

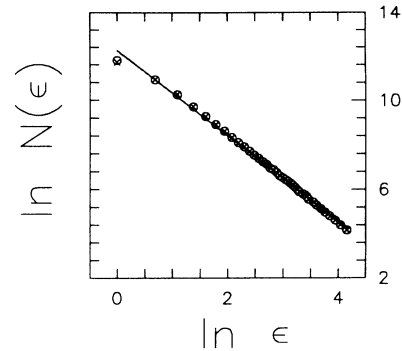


FIG. 2. Log-log plot to compute the box-counting dimension D_0 for micrographs 1(a) (empty circles) and 1(b) (crosses). The line is the least-squares fit, with slopes 1.88 ± 0.09 and 1.89 ± 0.08 , respectively.

by Chhabra and Jensen.²¹ Their algorithm gives directly the multifractal spectrum $f(\alpha)$ by pure scaling without invoking further numerical treatment and has very useful properties. Its description is a bit long, and hence we refer the reader to Ref. 21.

III. RESULTS AND DISCUSSION

Our results, shown in Figs. 2–4, indicate clearly that the set of Al crystals, with the measure we have introduced above, has a well-defined multifractal structure. As an example of the scaling range and the quality of the corresponding power-law behavior, we show in Fig. 2 the log-log graph from which the box-counting (D_0) dimension is obtained; other dimensions D_q are obtained by means of analogously good fits, especially for positive q . As for D_0 , it turns out to be 1.88 ± 0.09 , where we also take into account the slight shifts induced by the different backgrounds. Several remarks are in order regarding our computations. First, the spectrum is rather insensitive either to the precise value of the background threshold, a property that we have checked, computing the spectra taking different background values in a wide range, or to the specific area of the sample whose spectrum we compute, as we have also verified by studying several of them. Second, there is an extremely good agreement be-

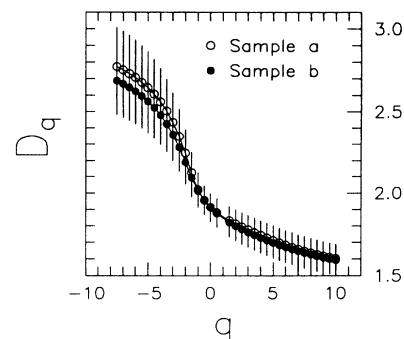


FIG. 3. Generalized dimensions D_q for micrographs 1(a) (empty circles) and 1(b) (full circles). Line is only a guide to the eye.

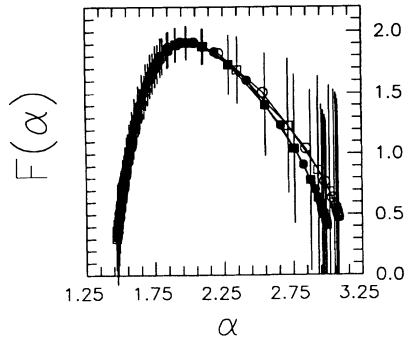


FIG. 4. Multifractal spectra $f(\alpha)$ for micrographs 1(a) (empty circles and squares) and 1(b) (full circles and squares). Line is only a guide to the eye. Circles are computed by numerical Legendre transform of the generalized dimensions shown in Fig. 3, squares are obtained from Chhabra-Jensen algorithm.

tween both methods for computing the $f(\alpha)$ spectrum, which can be seen in Fig. 4. Third, even with the improved Chhabra-Jensen algorithm, the computation error is large in the negative q region; however, these errors are (at least in a q interval near zero) not compatible with a single dot for $f(\alpha)$, which would correspond to a usual fractal (nonmultifractal),^{2,4} a result strongly supported by the precise calculation for positive q . Finally, we have checked the verification of known mathematical properties, with good results: it can be seen from Figs. 3 and 4 that $f(\alpha = D_1) = D_1$, and that the straight line with unit slope is tangent to $f(\alpha)$ at that point, as should happen.^{2,4}

We have also carried out some computations on the crystals' geometry, suppressing the distinction between regions with different degrees of darkness by setting all nonzero pixels to a value 1 (equivalently, now the measure is zero if the considered pixel does not belong to an Al crystal and one if it does belong to an Al crystal). By this procedure we may distinguish between multifractality coming from the fact that we have a non-uniform measure defined on a single fractal, or geometric multifractality^{4,11} induced by the very structure of the pattern. Unfortunately, this two-valued measure gives rise to much larger errors, and we have only been able to obtain reliable values for the generalized dimensions for positive q , which we plot in Fig. 5. Our results are not conclusive as to whether the geometry of crystals is multifractal or not, but it is clear that its multifractal nature is much less pronounced than that arising when the optical density is taken into account.

Concerning the question of the physical reasons for the formation of these multifractal patterns, we believe that the main factor influencing the process is the very rapid solidification through which those structures are produced. Indeed, there exists a close relationship between cooling rates and pattern formation: low solidification velocities ($\sim 10^3 - 10^5$ K s⁻¹) usually lead to dendritic growth and crystalline metastable phases, whereas higher velocities ($\sim 10^6 - 10^8$ K s⁻¹) give rise to α -Al plus GeAl amorphous phases.^{19,22} In our case, the process is even faster (10^9 K s⁻¹), and it happens in two

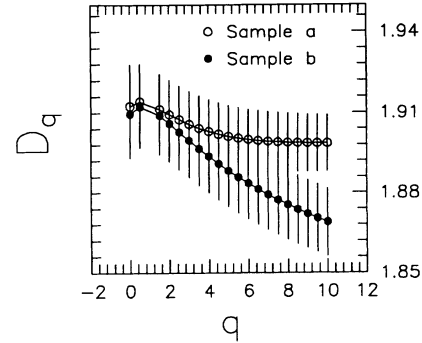


FIG. 5. Generalized dimensions when all nonzero pixels have been set to one for micrographs 1(a) (empty circles) and 1(b) (full circles). Line is only a guide to the eye.

stages: first, the laser pulse melts the multilayer film which immediately begins to mix through liquid phase diffusion; second, when energy deposition ends, the diffusion front is suddenly quenched. As the structure of diffusion fronts behaves similarly to those of percolation processes (see, e.g., Ref. 23), it could be possible that we are seeing crystals grown at clusters that were originated by a percolationlike phenomenon. Crystals would grow only in these clusters because their Al content would be high enough to become nucleant for crystallization but not too large as to prevent Ge from diffusing inside the Al crystals (see below). As an estimation, we may recall that the Al percolation threshold for GeAl systems is rather high, around 0.6 (see, Ref. 18 and references therein): hence, only the deep, Al-rich region near the substrate would support those Al clusters. It is also important to realize that if the diffusion process were completed, the sample would become homogeneous, and Al cellular crystals could not be formed. Finally, Ge diffuses into the Al clusters, enhances their contrast in the micrographs and seems to be mainly responsible for the multifractal measure. This factor imposes a further spatial limit for the process, namely, that it must happen near the innermost layer interface reached by the liquid front in order to have some Ge diffused into liquid Al but in an amount small enough to inhibit amorphous phase formation; this conclusion is in agreement with the location of the Al crystals seen in the irradiated samples.²⁰ The whole process would then occur in a thin slice of the sample near the substrate. The underlying percolation class phenomenon might also explain the large value (1.88 ± 0.09) of the fractal dimension of the patterns (recall that two-dimensional percolation clusters near the threshold have similar dimensions^{2,4}).

IV. CONCLUSION

Laser irradiation can induce formation of multifractal patterns in GeAl thin multilayer films. Their generalized dimensions and multifractal spectra computed by two methods are in very good agreement. A possible explanation for the physical origin of such multifractality is suggested, based on the fact that a diffusion process can form percolationlike interface structures through a rapid solidification process, preventing the appearance of other patterns like dendrites, which in addition are formed at

much lower quenching rates. Nevertheless, further theoretical work is needed to completely explain this phenomenon.

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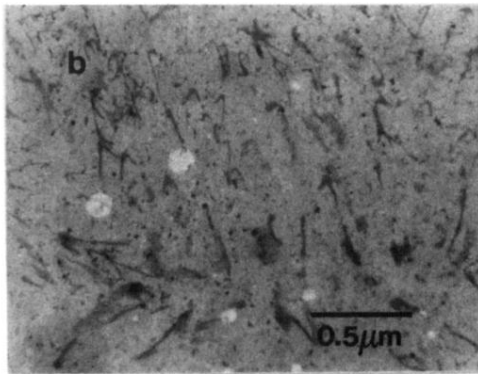
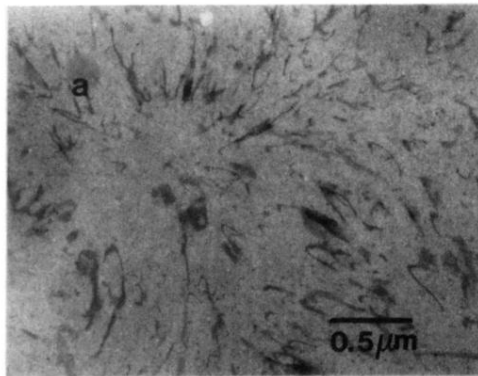


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